

IN THE SPECIFICATION

Kindly replace the paragraph at page 19, lines 1-9 by the following paragraph:

-- Reference is now made to Fig. 4A which is a schematic illustration of multi-element impedance probe 40 comprising an x-ray absorbing (non-radiolucent) alignment mark 210 on otherwise radiolucent or partially radiolucent impedance probe 40. Alignment mark 210 may be formed of a material that is sufficiently absorbing to show on the x-ray image, but not so absorbing that it can cause artifacts, for example, it is formed of aluminum. Alignment mark 210 may comprise at least two or three lines 212. Lines 212 may be arranged so as to provide at least one and preferably two junctions 214. Lines 212 and junctions 214 may be visible. Alternatively or additionally, their locations on impedance probe 40 may be known. Lines 212 may be a substantial distance apart with respect to the size of impedance probe 40. X-ray imaging may be performed with impedance probe 40 in place. --